Environmental Barrier Coatings Made by Different Thermal Spray Technologies

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Abstract: Environmental barrier coatings (EBCs) are essential to protect ceramic matrix composites against water vapor recession in typical gas turbine environments. Both oxide and non-oxide-based ceramic matrix composites (CMCs) need such coatings as they show only a limited stability. As the thermal expansion coefficients are quite different between the two CMCs, the suitable EBC materials for both applications are different. In the paper examples of EBCs for both types of CMCs are presented. In case of EBCs for oxide-based CMCs, the limited strength of the CMC leads to damage of the surface if standard grit-blasting techniques are used. Only in the case of oxide-based CMCs different processes as laser ablation have been used to optimize the surface topography. Another result for many EBCs for oxide-based CMC is the possibility to deposit them by standard atmospheric plasma spraying (APS) as crystalline coatings. Hence, in case of these coatings only the APS process will be described. For the EBCs for non-oxide CMCs the state-of-the-art materials are rare earth or yttrium silicates. Here the major challenge is to obtain dense and crystalline coatings. While for the \( \text{Y}_2\text{SiO}_5 \) a promising microstructure could be obtained by a heat-treatment of an APS coating, this was not the case for \( \text{Yb}_2\text{Si}_2\text{O}_7 \). Here also other thermal spray processes as high velocity oxygen fuel (HVOF), suspension plasma spraying (SPS), and very low-pressure plasma spraying (VLPPS) are used and the results described mainly with respect to crystallinity and porosity.

Keywords: environmental barrier coatings; thermal spray methods; atmospheric plasma spraying; suspension plasma spraying; very low-pressure plasma spraying; high velocity oxygen fuel spraying

1. Introduction

Ceramic materials often show unique high temperature capability. However, monolithic ceramics suffer from an intrinsic low fracture toughness and, hence, for demanding high temperature applications as blades, vanes, shrouds or transition ducts of turbine engines reinforced ceramics have to be used [1]. Even sensitive parts can be made from such ceramic matrix composites (CMCs) and this has been demonstrated in the last years by different industries especially by GE [2]. For applications with higher mechanical loads, typically, non oxide CMCs as SiC/SiC are used due to their excellent high temperature strength and creep properties. However, also oxide/oxide composites which are mainly based on alumina and typically have reduced high temperature properties are of interest for specific applications e.g., combustion chamber applications [3]. In contrast to their metallic counterparts, CMCs do not have to be protected against oxidation as SiC forms a well-protecting silica scale and
the oxide-based ceramics are anyhow stable at high temperatures in oxidizing atmosphere. However, these oxides tend to be rather unstable in the gas turbine atmosphere, namely water vapour containing combustion gases having velocities above 100 m/s and temperatures above 1100 °C. In this environment volatile (oxy) hydroxides are formed which remove the scale and can lead to a massive damage of the hole component [4,5]:

\[ \text{SiO}_2 + 2 \text{H}_2\text{O} \rightarrow \text{Si(OH)}_4 \uparrow \text{ or } \text{Al}_2\text{O}_3 + 3 \text{H}_2\text{O} \rightarrow 2 \text{Al(OH)}_3 \uparrow \] (1)

This water vapor recession can be addressed by coatings using highly corrosion-resistant materials (so-called environmental barrier coatings (EBCs)). Many interesting materials have been tested in high velocity and high-temperature and water vapor environments. The recession rates and coefficients of thermal expansion of most of the EBC materials and CMCs of interest in this study are summarized in Figure 1. The recession rate and the thermal expansion coefficient (TEC) is plotted for different materials and the values for two CMC materials are given, an SiC/SiC and an alumina-based Ox/Ox composite. Additionally, Gd\(_2\)Zr\(_2\)O\(_7\) (CTE = 10.6 × 10\(^{-6}\) K\(^{-1}\)) was considered and was shown to have the lowest recession rate among pyrochlore materials successfully used for thermal barrier coating (TBC) application [6,7]. Generally, suitable EBC materials should have low corrosion rates and TECs close to the used CMC.

![Figure 1](image-url). Recession rate and thermal expansion coefficient for EBC materials relevant to this study (blue) and the SiC/SiC and Al\(_2\)O\(_3\)/Al\(_2\)O\(_3\) composites (red) (Data from [8–10]).

Compared to thermal barrier coatings (TBCs) EBCs should have a low porosity level to avoid the access of water vapour to the CMC. This will lead to rather high Young’s moduli \(E_{EBC}\) in the EBCs close to the bulk values. A high Young’s modulus is not favourable with respect to failure of the coatings as it increases the stored elastic energy; if this so-called energy release rate \(G\) exceeds a critical value \(G_c\), a crack can propagate and failure occurs. The energy release rate can be calculated under plane stress conditions for a homogeneous coating stress \(\sigma\) and an infinite crack as:

\[ G = \frac{\sigma^2h}{2E_{EBC}} \] (2)
with $h$ being the coating thickness. If the stress in the coating relaxes at high temperature, the stress at room temperature is for a thin coating determined by the mismatch of thermal expansion coefficients:

$$\sigma = E_{EBC}(\alpha_{EBC} - \alpha_{CMC}) \Delta T$$  \hspace{1cm} (3)

As the square of TEC mismatch is determining the energy release rate in (2) a large mismatch should be avoided. Thickness and Young’s modulus have a linear influence on it.

The most often used technology to apply EBCs is thermal spray. Thermal spray is a versatile coating process in which the feedstock material is accelerated by a process gas and in most cases heated in powder form and then deposited on the substrate [11]. In thermal spray processes, the bonding between coating and substrate is mainly due to mechanical interlocking at asperities of the substrate surface. A sufficient bonding is typically achieved by a grit-blasting process prior to the deposition. However, it was found that for low strength materials as oxide-based composites this treatment can lead to significant degradation of the material. Hence, new methods as laser ablation to structure the surface will be discussed in the present paper.

In the thermal spray process, the molten particles will impinge on the substrate, the deformed droplets (“splats”) will cool down quickly and generate large tensile stresses which typically introduce cracks [12]. These cracks form an open network which allow the diffusion of gas species through it and hence, such coatings will delay the water vapor corrosion but can hardly avoid it. In order to form gas-tight coatings rather hot spraying conditions with high substrate temperatures (above 500°C) and complete melting of the feedstock are beneficial. Such conditions can lead to a re-melting of already deposited splats and by this improve the bonding in the coating. Such approaches have been used to produce gas-tight electrolytes with a thickness below 50 µm from yttria stabilized zirconia (YSZ) for solid oxide fuel cells [13]. It was also demonstrated that high particle velocities at impact (>300 m/s) are favourable. Similar process conditions are also used to deposit segmented TBCs. In this process very dense coatings are produced by APS leading also to high tensile stresses in the coatings [14]. If a certain thickness (typically about 100 µm) is reached, the energy release rate exceeds the critical one and segmentation cracks are formed. This is of course not wanted for EBC applications. The segmentation cracks are driven by the cooling of the splats and hence by the absolute TEC of the ceramic coating material and not by the mismatch to the substrate. As a result EBCs for SiC/SiC should be less prone to segmentation cracks then those for Ox/Ox CMCs assuming the same other materials properties (Young’s modulus, toughness).

In addition to the difficulty to produce very dense coatings another issue is often important for EBCs. The materials used tend to form an amorphous phase when cooled down quickly from the molten state to the substrate temperature. This is detrimental, as the coatings will typically crystallize during operation, which is accompanied by a volume reduction and pore/crack formation in the coating. So, a highly crystalline coating in the as-sprayed condition is desirable. Previous results indicate that high deposition temperatures are favourable as then the time at temperature for crystallization is sufficient. It was proposed to deposit coatings in a furnace [15], however, we try in our approaches to avoid it as it introduces additional process steps and hence costs.

For the deposition of the EBCs we have investigated four different thermal spray processes (see Figure 2). Basic requirements for the processes are the capability to reach high feedstock temperatures and velocities.

First of all, atmospheric plasma spraying (APS) will be considered as a kind of standard baseline process. Here a fast variant (high velocity APS, HV-APS) will be described. The APS process shows a high temperature of the process gases (>10000 K at the nozzle exit) due to the efficient heating by electric arcs. Hence, a good and fast heat-transfer to the particles is possible, which allows complete particle melting, however can also lead to loss of those constituents in the powder with high vapor pressure. Typical velocities are in the range of 200-300 m/s, however specific conditions as small nozzle diameter and larger amounts of process gas allow higher velocities (up to 500 m/s, HV-APS)
While in the APS process particle in the range of several 10 micrometers (see splat in Figure 2) are used, the suspension plasma spraying allows much finer droplets and splats due to the use of suspensions. Here the droplet size is determined by a complex atomization process. The droplets typically in the size range of micrometers can easily reach the temperature and velocities of the process gas, hence both are typically higher than in APS. If the right suspension properties are chosen this can lead to improved densities, however also some more significant loss of volatile species can be expected due to the higher surface area of the droplets.

The plasma guns can also be operated in inert gas environment. For that a vacuum chamber is evacuated and then refilled by inert gas to typical pressures of about 50 mbar. The process is often used to deposit metals to avoid in-flight oxidation. Due to the expansion of the plume into a chamber with reduced pressure, the gas velocities are higher than in APS. In our used equipment, powerful pumping units allow to maintain even lower chamber pressures in the mbar range during operation (Very low-pressure plasma spraying-VLPPS). This leads to even higher gas and particle velocities (see the large expanding plume in Figure 2) with corresponding high coating densities. In addition, the used powerful gun and the reduced cooling by convection allows homogenous high substrate temperatures which support dense and crystalline coating formation. This could be demonstrated for the deposition of dense ceramic membranes [16].

The last process which will be considered is a combustion process, the high velocity oxygen fuel (HVOF) spraying. The maximum gas temperature is limited to temperatures slightly above 3000 °C, so the heating of the feedstock is limited. On the other hand, the use of a de Laval nozzle allows extremely high, supersonic gas velocities (see shock diamonds in Figure 2) and corresponding high particle velocities. With such high velocities dense coating might be possible even without complete melting of the feedstock. Such a particle with non-molten core is visible in Figure 2.

An additional more detailed description of some of the results can be found in our previous papers [17–20].

**Figure 2.** Characteristics of the 4 investigated thermal spray processes (Axial III used for SPS, TriplexPro210 for APS, O3CP for VLPPS, DJ2700 for HVOF) showing plume temperatures and particle velocities, photos of the plumes plus conditions used (process gases, current in case of plasma processes, and stand-off distances), and photos of typical splats.

### 2. Materials and Methods

#### 2.1. Feedstock Materials, Suspensions and Substrates

Different feedstock powders have been used for the investigations, Table 1 gives an overview of the used materials.
Table 1. Description of the used feedstock materials.

<table>
<thead>
<tr>
<th>Material</th>
<th>Manufacturer</th>
<th>Mean particle Size $d_{50}$ [mm]</th>
<th>Process Used</th>
<th>Impurity Phases [wt.%]</th>
</tr>
</thead>
<tbody>
<tr>
<td>$Y_2SiO_5$-YS</td>
<td>Treibacher Industrie AG</td>
<td>34</td>
<td>APS</td>
<td>$7% Y_2O_3$</td>
</tr>
<tr>
<td></td>
<td></td>
<td></td>
<td></td>
<td>$5% Y_2SiO_3$</td>
</tr>
<tr>
<td>$Yb_2Si_2O_7$-YDS</td>
<td>Oerlikon Metco (US) Inc.</td>
<td>49</td>
<td>APS/VLPPS HVOF</td>
<td>$5% Yb_2SiO_3$</td>
</tr>
<tr>
<td>$Gd_2Zr_2O_7$</td>
<td>IEK-1</td>
<td>$&lt;30$</td>
<td>APS</td>
<td>-</td>
</tr>
<tr>
<td>$Y_3Al_5O_12$</td>
<td>Treibacher</td>
<td>30</td>
<td>APS</td>
<td>-</td>
</tr>
<tr>
<td>$Y_2O_3$</td>
<td>Oerlicon Metco Europe GmbH</td>
<td>32</td>
<td>APS</td>
<td>-</td>
</tr>
<tr>
<td>$Yb_2Si_2O_7$-YDS</td>
<td>IEK-1</td>
<td>3.1</td>
<td>SPS</td>
<td>$5% Yb_2SiO_3$</td>
</tr>
</tbody>
</table>

For SPS purposes, YDS powder was milled in ethanol with the addition of polyethylenimine (PEI) and zirconia milling balls ($d = 3$ mm). The mixture was milled on roller cylinder ($60$ min$^{-1}$, $48$ h) in order to produce a homogeneously-dispersed suspension (30 wt % in solid content). After milling, the suspension was diluted with ethanol to $10$ wt % of solid loading and the particle size distribution was $d_{10} = 1.3$ µm, $d_{50} = 3.1$ µm, and $d_{90} = 5.0$ µm.

As substrates different materials have been taken as carbon steel, graphite, monolithic SiC and partly CMCs as 2d C/SiC (Schunk CF 226 P 75), SiC/SiCN (provided by DLR Stuttgart [21]) and an alumina based CMC FW12 (Walter E. C. Pritzkow Spezialkeramik, Filderstadt-Sielmingen, [22]). In the case of YS, a bond-coated IN738 was used as substrate for preliminary tests.

2.2. Thermal Spray Facilities

At IEK-1 different thermal spray systems for the deposition of ceramic coatings with high particle velocities are available. The “work horse” is a MultiCoat system (Oerlikon Metco, Wohlen, Switzerland) which was operated in this study for APS with the three-cathode TriplexPro 210 and for HVOF with the Diamond Jet 2700 spray torches both mounted on a six-axis robot (IRB 2400, ABB, Zurich, Switzerland). For the suspension plasma spraying a different spray booth equipped with the Axial III plasma torch with three separate cathode-anode pairs (Mettech Northwestern Corp., North Vancouver, BC, Canada) which allowed the axial injection of the liquid feedstock was used. As feeding system a home-made device was employed.

Vacuum plasma spraying was performed in a MultiCoat platform (Oerlikon Metco, Wohlen, Switzerland) with a 6 m$^3$ tank volume. Here the powerful O3CP torch (Oerlikon Metco, Wohlen, Switzerland) was chosen as plasma torch. The deposition temperatures were monitored by infrared pyrometers in each processing method.

An overview of the employed spray parameters is found in Table 2. The parameter used are based on long-year experience in the thermal spray of ceramics. Some further optimization trials have been made especially for EBC materials for oxide-based CMCs but they are not shown here. As shown in the results, the coating microstructure appears rather dense and often crystalline, no efforts to further optimize the microstructure were made. In the case of YDS the APS coating properties were not satisfying, here also other techniques have been investigated.

2.3. Surface Treatment

All samples were ultrasonically cleaned before spraying. To increase the adhesion properties, some of the Al$_2$O$_3$/Al$_2$O$_3$ CMC samples were pre-treated mechanically or by laser ablation. The mechanical pre-treatment was carried out with 80-grit sandpaper or by grit blasting with F 36 powder.
Table 2. Overview of the used thermal spray conditions (YS = Y_2SiO_5, YBDS = Yb_2Si_2O_7)

<table>
<thead>
<tr>
<th>Process</th>
<th>APS</th>
<th>HVOF</th>
<th>VLPPS</th>
<th>SPS</th>
</tr>
</thead>
<tbody>
<tr>
<td>Torch</td>
<td>Triplex Pro 210</td>
<td>DJ2700</td>
<td>O3CP</td>
<td>Axial III</td>
</tr>
<tr>
<td>Process gases [slpm]</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>YS:46Ar/4H_2 or 4He, YDS: 46Ar/4H_2</td>
<td>Gd_2Zr_2O_7: 46 Ar/4He</td>
<td>Yb_2Si_2O_7: 46 Ar/4He</td>
<td>Y_3Al_5O_12: 50 Ar/4He</td>
<td>Y_2O_3: 46 Ar/4He</td>
</tr>
<tr>
<td>YDS: O_2 395/CH_4 190</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Power[kW]</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>YS: He: 50, H_2: 58, YDS: 57</td>
<td>Gd_2Zr_2O_7: 50Yb_2Si_2O_7: 49.7</td>
<td>Y_3Al_5O_12: 44.4</td>
<td>Y_2O_3: 50.8</td>
<td></td>
</tr>
<tr>
<td>YDS: O_2 395/CH_4 190</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>Stand-off distance [mm]</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>YS: 90/120</td>
<td>Gd_2Zr_2O_7: 120</td>
<td>Yb_2Si_2O_7: 120</td>
<td>Y_3Al_5O_12: 70</td>
<td>Y_2O_3: 120</td>
</tr>
<tr>
<td>YDS: 325</td>
<td>YDS: 700</td>
<td>YDS: 50/70/90</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Substrate temperature [°C]</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>YS: 460-750</td>
<td>Gd_2Zr_2O_7: 500</td>
<td>Yb_2Si_2O_7: 600</td>
<td>Y_3Al_5O_12: 700</td>
<td>Y_2O_3: 500</td>
</tr>
<tr>
<td>YDS: 150</td>
<td>YDS: 1000</td>
<td>YDS: 720/650/620</td>
<td></td>
<td></td>
</tr>
<tr>
<td>Substrates</td>
<td></td>
<td></td>
<td></td>
<td></td>
</tr>
<tr>
<td>YS: IN738, C/SiC, YDS: SiC</td>
<td>Gd_2Zr_2O_7: Al_2O_3/Al_2O_3</td>
<td>Yb_2Si_2O_7: Al_2O_3/Al_2O_3</td>
<td>Y_3Al_5O_12: Al_2O_3/Al_2O_3</td>
<td>Y_2O_3: Al_2O_3/Al_2O_3</td>
</tr>
<tr>
<td>YDS: Steel and SiC/SiCN</td>
<td>YDS: Steel and SiC/SiCN</td>
<td>Monolithic SiC</td>
<td></td>
<td></td>
</tr>
</tbody>
</table>

A pulsed laser Trumpf TruMark 5020 with a wavelength of 1062 nm (Nd:YAG), 50 ns pulse duration and a maximum peak power of 15 kW was used for surface structuring (Trumpf GmbH + Co. KG, Ditzingen, Germany). The used laser parameters are given in Table 3. For a more detailed description of the ablation process the reader is referred to Gatzen et al. [23]

Table 3. Used laser parameters for surface structuring of Al_2O_3/Al_2O_3 CMCs.

<table>
<thead>
<tr>
<th>Structure</th>
<th>Pulses Per Point</th>
<th>Program Repetition</th>
<th>Dot Distance (μm)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Honeycomb</td>
<td>1</td>
<td>50</td>
<td>30</td>
</tr>
<tr>
<td>Cauliflower</td>
<td>50</td>
<td>1</td>
<td>30</td>
</tr>
</tbody>
</table>

2.4. Characterization

After spraying the samples were sectioned, polished, and examined with a scanning electron microscope (Carl Zeiss NTS GmbH, Oberkochen, Germany) combined with an energy-dispersive X-ray INCAEnergy355 spectrometer (EDS, Oxford Instruments Ltd., Abingdon, Oxfordshire, UK). Alternatively, SEM images were taken with a Hitachi TM3000 (Hitachi, Krefeld, Germany). Acquired SEM images were employed to assess the porosity in the coatings by means of image analysis using an image thresholding procedure with the analysis pro software (Olympus Soft Imaging Solutions GmbH, Germany). The analysis was performed on 10 SEM micrographs (2000× magnification) per sample, each with a resolution of 1280 × 1100 pixels and covering a horizontal field width of 126 μm. Crack density values of samples manufactured by suspension plasma spraying were calculated from the number of vertical cracks by using 15 SEM images (with ×300 magnification and width of 600 μm) as well.

X-ray diffraction analysis was performed with a D4 Endeavor with Cu-Kα radiation (λ = 1.54187 Å) & TOPAS software V4.2, Bruker AXS, Germany. In addition to the Rietveld method, also amorphous content and quantitative phase analysis (QPA) was used to evaluate crystalline phases and amorphous
contents in the coatings (see [17] for details). High-temperature XRD (HT-XRD) was performed at the PANalytical Empyrean diffractometer in Bragg-Brentano geometry using a Cu Kα anode and an environmental heating chamber HTK1200N (Anton Paar GmbH, Ostfildern, Germany) between room temperature and 1400 °C.

The surface profiles were measured by white light interferometry (cyberTechnologies, CT350T, Eching, Germany).

The EBC systems on oxide/oxide composites were also thermally cycled at 1200°C in a furnace. The heating and cooling rates were +/- 10 K/min, immediately after reaching room temperature the next cycle was started. 4 of these cycles have been made for each coating system. Thermal cycling is seen as a tool to characterize the bonding in the case of the EBC for oxide-based CMCs and hence the efficiency of the surface treatment.

3. Results and Discussion

3.1. APS Coatings on OxOx CMCs

Coatings of Y₂O₃, Gd₂Zr₂O₇, Y₃Al₅O₁₂ and Yb₂Si₂O₇ were applied on the untreated and cleaned substrates. XRD measurements of as-sprayed samples were carried out. The measurements are plotted in Figure 3, signals that cannot be attributed to the desired phase were marked with an asterisk (*). The XRD measurements of Y₂O₃ and Gd₂Zr₂O₇ show the diffraction patterns of the corresponding phases, no signals from secondary phases were observed. The coatings appear to have a high crystallinity. In contrast to this, the XRD measurements of Y₃Al₅O₁₂ and Yb₂Si₂O₇ coatings show humps, which indicate the presence of large amounts of amorphous phases. Due to the low crystallinity not all phases could be identified. The XRD measurements of the Y₃Al₅O₁₂ coating shows the diffraction pattern of Y₃Al₅O₁₂ and YAlO₃. The formation of the alumina depleted phase YAlO₃ is attributed to evaporation of alumina during the spraying process, since the vapor pressure of Al₂O₃ is higher than that of Y₂O₃ [24]. The XRD measurement of the Yb₂Si₂O₇ coating shows no reflections of the desired phase. Besides the large amorphous hump, the diffraction pattern of Yb₂O₃ was observed. The high amorphous content of the Y₃Al₅O₁₂ and Yb₂Si₂O₇ coatings might cause crystallization stress in the coating during thermal treatment.

![Figure 3](image_url)

**Figure 3.** XRD measurements of Y₂O₃, Gd₂Zr₂O₇, Y₃Al₅O₁₂ and Yb₂Si₂O₇ coatings in the as-sprayed state, peaks of secondary phases are marked with *.

The as-sprayed samples were subjected to furnace thermal cycling, the used temperature program consists of four 20 h cycles at 1200 °C. SEM images of cross sections of samples in the as-sprayed state
and after thermal cycling are presented in Figure 4. Additionally, higher magnification images of the interface region of the coatings are presented in Figure 5.

Figure 4. SEM-images of $Y_2O_3$, $Gd_2Zr_2O_7$, $Y_3Al_5O_{12}$ and $Yb_2Si_2O_7$ APS coatings on Ox/Ox CMCs before (left) and after thermal cycling (right).
The obtained Y$_2$O$_3$ coatings were dense and fully crystalline. The adhesion of the Y$_2$O$_3$ samples seems to be quite good, after heat treatment no signs of cracks or delamination are observed. The good adhesion can be attributed small TEC mismatch and phase stability, resulting in low driving force for delamination. Another reason for the good adhesion is the formation of yttrium-aluminates at the coating substrate interface leading to chemical bonds between coating and substrate [25]. In Figure 5 the formation of several yttrium-aluminates known from the phase diagram [26] can be observed.

The SEM images of the Gd$_2$Zr$_2$O$_7$ coatings show dense and homogenous coatings in the as-sprayed state. Figure 5 shows the coating substrate interface in detail. After thermal cycling no sign of a reaction between Gd$_2$Zr$_2$O$_7$ and Al$_2$O$_3$ was observed. This is in contrast to Lakiza et al. [27] and Leckie et al. [28] The phase diagram of Gd$_2$Zr$_2$O$_7$, presented by Lakiza et al. [27], suggests formation of gadolinium-aluminates such as GdAlO$_3$ and Gd$_4$Al$_2$O$_9$. The reaction between Gd$_2$Zr$_2$O$_7$ and Al$_2$O$_3$ to GdAlO$_3$ was observed in a study by Leckie et al. [28]. The absence of this reaction in this study can be explained by bad wetting which causes only small contact areas to the substrate, as a consequence the reaction is inhibited. However, after heat treatment the coating was delaminated at the interface (marked by arrows in Figure 4). This can be explained by the TEC mismatch ($\Delta$CTE = $3 \times 10^{-6}$ K$^{-1}$, see Equations (2) and (3)) and bad wetting of the relative smooth substrate ($R_a = 2.6 \mu m$).

The SEM images of the Y$_3$Al$_5$O$_{12}$ coating confirm the presence of secondary phases within the coating. Furthermore, large round pores can be observed in the Y$_3$Al$_5$O$_{12}$ coatings. The high porosity is not favourable for an EBC, as pores and cracks increase the permeability for water vapor. Despite the low TEC mismatch ($\Delta$CTE = $3 \times 10^{-6}$ K$^{-1}$), the Y$_3$Al$_5$O$_{12}$ coatings tend to fail during thermal cycling. This can be explained by the high amorphous content of the APS-Y$_3$Al$_5$O$_{12}$ coatings. Thermal treatment leads to crystallization and phase transformation of the coating; this causes stress within the material leading to the formation of segmentation and delamination cracks. The formation of large pores in Y$_3$Al$_5$O$_{12}$ coatings was also reported by Weyant et al. [29], a dependence between crystallization, substrate temperature and porosity was assumed. According to the phase diagram [30] of Y$_2$O$_3$ and Al$_2$O$_3$, a reaction between coating and substrate is not expected. The SEM image of the Y$_3$Al$_5$O$_{12}$ - Al$_2$O$_3$ interface (Figure 5) shows that unlike with Y$_2$O$_3$, no reaction occurs between substrate and coating.

The cross-sections show that the disilicate coatings have a lot of pores and consist of several phases, which is, again, not favourable for an EBC. Furthermore, crystallization problems occurred,
as described for the $Y_3Al_5O_{12}$ coatings. Due to the high TEC mismatch ($\Delta_{\text{CTE}} = 5.2 \times 10^{-6} \text{ K}^{-1}$, see Equations (2) and (3)) and the stresses that arise during crystallization, these coatings were delaminated during thermal treatment. According to the phase diagram of $Yb_2O_3-SiO_2-Al_2O_3$ [31], the formation of mullite ($Al_6Si_2O_{13}$) and ytterbium-aluminates ($Yb_4Al_2O_9$, $Yb_3Al_5O_{12}$) during thermal cycling is possible. However, no reaction between coating and substrate was observed (see Figure 5). The absence of a reaction layer may be attributed to the loose contact between coating and substrate as well as the high TEC mismatch and the resulting premature coating delamination.

Due to the high coating crystallinity, phase purity and coating density, $Gd_2Zr_2O_7$ and $Y_2O_3$ were chosen for further experiments. Although $Gd_2Zr_2O_7$ has a higher CTE mismatch, it is a desirable top coat due to its excellent CMAS stability. In order to increase the coating adhesion different methods of surface preparation were carried out before spraying.

First, samples of the $Al_2O_3/Al_2O_3$ CMC were mechanically treated to increase the surface roughness. Some samples of the $Al_2O_3/Al_2O_3$ CMC were ground, others were grit-blasted. Both methods were able to increase the surface roughness from 2.6 $\mu$m to 5.1 $\mu$m and 15 $\mu$m, respectively. The samples were coated and subsequently furnace cycled for $4 \times 20$ h at 1200 °C. SEM images of cross-sections of the as-sprayed $Y_2O_3$-coatings as well as furnace cycled samples are shown in Figure 6. The results show that the mechanical pre-treatment damaged the ceramic substrate to such an extent that even $Y_2O_3$ coatings failed. Unlike in the study of Gérendas et al. [32], mechanical pre-treatment was not able to achieve sufficient coating adhesion on this CMC.

![SEM images of APS-Y$_2$O$_3$ coatings on Ox/Ox CMCs with and without mechanical pre-treatment before and after thermal cycling.](image-url)
Laser ablation was used for surface structuring without damaging of the substrates. The positive effect of laser surface structuring of Al<sub>2</sub>O<sub>3</sub>/Al<sub>2</sub>O<sub>3</sub> CMCs on coating adhesion was recently demonstrated by Gatzen et al. [23]. Two different structures were chosen for this study: honeycomb and cauliflower structure. Both structures are illustrated in Figure 7.

![Surface profiles, white light topography and SEM images of ox/ox CMC before (top) and after structuring by laser ablation (middle, bottom).](image)

Figure 7. Surface profiles, white light topography and SEM images of ox/ox CMC before (top) and after structuring by laser ablation (middle, bottom).

The untreated substrate has a roughness of about 2.6 µm and a homogenous smooth surface. Few cracks and pores at the surface offer possibilities for clamping. The cauliflower like surface structure comprises an irregular and inhomogeneous surface of re-solidified alumina. An average roughness of 10.8 µm was achieved with this pattern. The honeycomb structure shows well-defined holes close to each other. A roughness of about 5.7 µm was measured for this pattern. Both surface structures offer more possibilities for clamping, therefore, an increase in lifetime is expected especially for Gd<sub>2</sub>Zr<sub>2</sub>O<sub>7</sub> coatings.

After structuring the samples were coated with Y<sub>2</sub>O<sub>3</sub> and Gd<sub>2</sub>Zr<sub>2</sub>O<sub>7</sub>. SEM images of the coated and thermally cycled samples are shown in Figure 8. Both coatings could infiltrate the voids in between the substrate structure. The surface structures, especially the cauliflower structure, allow interlocking of the coating. After thermal cycling no cracks or delamination occurred in the Y<sub>2</sub>O<sub>3</sub> coating-substrate-system. This shows that in contrast to grit-blasting and grinding, laser structuring of the CMC does not weaken the ceramic matrix. Furthermore, after thermal cycling of the laser-structured Gd<sub>2</sub>Zr<sub>2</sub>O<sub>7</sub> coated samples, the coating-substrate interface shows no delamination cracks. This is a significant improve, compared to the coating on untreated substrates. Although the energy release rate is high in these coatings with high mismatch (see Equations (2) and (3)), the laser structuring of the samples proofed to be beneficial for the coating adhesion (e.g., the critical energy release).
In addition, a third method of adhesion improvement was tested for Gd$_2$Zr$_2$O$_7$: the usage of an Y$_2$O$_3$-bondcoat. For this, the untreated substrate was first coated with Y$_2$O$_3$ and then coated with Gd$_2$Zr$_2$O$_7$. This double layer coating system is referring to the double layered TBCs as published by Vaßen et al. [33]. The Y$_2$O$_3$-bondcoat helps to buffer to some extent especially at edges the CTE mismatch between the CMC and Gd$_2$Zr$_2$O$_7$. Furthermore, the Y$_2$O$_3$ coating is known to be good adherent on Alumina CMCs [25] and offer a rough surface for the Gd$_2$Zr$_2$O$_7$ coating. Using Y$_2$O$_3$ as an interlayer between substrate and Gd$_2$Zr$_2$O$_7$ also proofed to increase the coating adhesion as well.

3.2. Development of APS Y$_2$SiO$_5$ coatings

According to Figure 1 Y$_2$SiO$_5$ has an excellent water vapor resistance and is therefore considered as appropriate EBC material [34,35]. In this investigation only rather hot APS spraying conditions are investigated for this material. The density of all the coatings manufactured by the investigated conditions (see Table 2) has been rather high, more interesting is the phase content which shows remarkable differences (see Figure 9). Compared to the He as secondary gas, hydrogen increased the plasma enthalpy which leads to higher substrate temperatures (750 °C) and increases the amount of crystallization. The comparable amount of SiO$_2$ in all coatings might indicate no significant differences in the silica loss during spraying (although the amorphous content is not considered).

Due to the highest crystallinity, the condition D with hydrogen and long stand-off distance (condition D) was used for further studies and coatings on C/SiC substrates were prepared. In Figure 10 SEM micrographs of the coatings in the as-sprayed condition and after annealing for 12 h at 1350 °C. First of all, the coating is also after the heat-treatment well-adherent. This indicates that the TEC mismatch (see Equations (2) and (3)) between coating and substrate seems to be not extremely detrimental (although the material would fit even better to Ox/Ox CMC substrates). In addition, also the phase transformation at 850 °C and the strongly anisotropic expansion of Y$_2$SiO$_5$ [36] obviously does not significantly affect coating integrity.

![Figure 8. SEM images of APS Y$_2$O$_3$ and Gd$_2$Zr$_2$O$_7$ coatings on laser structured Ox/Ox CMC substrates after thermal cycling (4 × 20 h at 1200 °C).](image-url)
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Figure 8. SEM images of APS Y$_2$O$_3$ and Gd$_2$Zr$_2$O$_7$ coatings on laser structured Ox/Ox CMC substrates after thermal cycling ($4 \times 20$ h at $1200 ^\circ C$).

In addition, the size of the segmentation and micro cracks is largely reduced due to sintering, some segmentation cracks are even no longer penetrating through the whole coating. Also the phase transformation at $850 ^\circ C$ and the strongly anisotropic expansion of Y$_2$SiO$_5$ [36] obviously does not significantly affect coating integrity.

In addition, the size of the segmentation and micro cracks is largely reduced due to sintering, some segmentation cracks are even no longer penetrating through the whole coating. Also the phase distribution changed significantly. While in the as-sprayed condition rather large regions with low and high silicon content appear (stemming from the impinging particles which have lost silicon during spraying mainly at their surface), the annealed coating shows much finer phases consisting of cubic Y$_2$O$_3$ (bright) and monoclinic Y$_2$SiO$_5$ (darker). The evolution of phases is shown in Figure 11 measured by XRD and using Rietveld refinement. Obviously, a short-term annealing at $1000 ^\circ C$ is not sufficient to form the equilibrium phases. As the coating is rather dense, the Y$_2$O$_3$ as a second phase has a reasonable corrosion resistance (Figure 1) and the microstructure probably will show some particulate toughening effects, the found coating is expected to perform good as EBC.

Figure 9. Phase evaluation of 4 Y$_2$SiO$_5$ coatings (caption indicate power, stand-off distance and secondary gas).

Figure 10. SEM micrographs of plasma-sprayed Y$_2$SiO$_5$ coatings (condition D) in the as-sprayed (a,b) and annealed (c,d, $1350 ^\circ C$, 12h) condition.
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![Figure 11. Phase evolution in APS $\text{Y}_2\text{SiO}_5$ coatings (condition D) after heat-treatment.](image)

### 3.3. $\text{Yb}_2\text{Si}_2\text{O}_7$ Coatings Manufactured by Different Thermal Spray Techniques for SiC/SiC Substrates

Figure 12 shows the phase composition of APS, HVOF and VLPPS coatings deposited from different particle size fractions of the same $\text{Yb}_2\text{Si}_2\text{O}_7$ feedstock. The main differences between the different methods are melting degree of the sprayed particles and deposition temperatures which define the crystallinity of the coatings as well as the degree of Si evaporation during spraying.

In APS and VLPPS, as a result of the high heat transfer from plasma to the particles, particles melt, impact on the substrate in the molten state and rapidly solidify on the substrate. High plasma powers were selected in the deposition of EBCs with APS (57 kW) and VLPPS (90 kW) as a dense microstructure consists of well-flattened particles with good interfacial contact is aimed. While high plasma powers ensure melting of particles in the plume, it also leads to a significant amount of Si-evaporation from $\text{Yb}_2\text{Si}_2\text{O}_7$ during spraying. As a result of that, Si-depleted secondary phases such as $\text{Yb}_2\text{SiO}_5$ and $\text{Yb}_2\text{O}_3$ are found in the as-sprayed coatings as shown in the Figure 12a. Furthermore, due to quenching of the molten particles on the substrate, that is at nearly room temperature if not pre-heated by plasma plume, crystallization of the glass forming silicates is suppressed and the amorphous phase is formed. The APS experiments carried out in order to increase the SiC substrate temperature by heating with plasma prior to deposition revealed that for a substrate size of 50 × 50mm$^2$, it is possible to increase the substrate temperatures up to about 800–900 °C however the temperature rapidly goes down to 500–550 °C till the deposition starts. As shown in Figure 12a, this deposition temperature range was found to be not sufficient to activate and complete the crystallization of the coating. According to HT-XRD analysis of amorphous plasma-sprayed $\text{Yb}_2\text{Si}_2\text{O}_7$ particles, which were collected in water and dried subsequently at 70 °C, the crystallization temperature of the material was found to be above 1000 °C, which explains the amorphous structure of the coating deposited at about 550 °C. Aiming at a higher substrate temperature as well as slower cooling rates in order to provide higher energy and longer time for the atoms to rearrange into the crystalline state, VLPPS experiments were conducted in the controlled atmosphere chamber (2 mbar). It was found that it is possible to reach substrate
temperatures higher than 1000 °C (Figure 13) owing to higher plasma power of the O3CP torch as well as to retain it till the deposition starts due to reduced heat transfer under vacuum. To prolong the high-temperature phase after deposition for some minutes, the coating was kept to be heated using the plasma plume and by this procedure, highly crystalline coatings could be produced as shown in Figure 12a. Nevertheless, it should be mentioned that Si-evaporation remains a problem as more than 10 wt.% Yb$_2$SiO$_5$ was detected in the VLPPS coatings.

Figure 11. Phase evolution in APS Y$_2$SiO$_5$ coatings (condition D) after heat-treatment.

3.3. Yb$_2$Si$_2$O$_7$ Coatings Manufactured by Different Thermal Spray Techniques for SiC/SiC Substrates

Figure 12 shows the phase composition of APS, HVOF and VLPPS coatings deposited from different particle size fractions of the same Yb$_2$Si$_2$O$_7$ feedstock. The main differences between the different methods are melting degree of the sprayed particles and deposition temperatures which define the crystallinity of the coatings as well as the degree of Si evaporation during spraying.

The HVOF process yields lower flame temperatures in comparison with the plasma spray processes as the flame is generated by combustion. As a result of that, particle temperatures as well as the deposition temperature are lower. Nonetheless, using the HVOF process, Yb$_2$Si$_2$O$_7$ coatings with higher crystallinity in comparison with the APS could be manufactured because of the deposition of un-melted or partially molten particles. This was avoided in the plasma spray processes as un-melted particles increase the porosity levels in the coatings due to imperfect contact regions as well as the porous morphology of the particle itself. In the HVOF process, however, not the porosity stemming from the particle morphology, but the porosity caused by the bad contact can be minimized thanks to very high flame velocity and, thus, the high momentum transfer to the particles in the flame. If the brittle oxide particles are completely un-melted, they break upon high-velocity impact on the
substrate, however, if only their core is un-melted and the outer surface is molten, they can adhere on the substrate or on the previously deposited layers. To reach such particle conditions, sensitive process optimizations are required in terms of fuel-oxygen stoichiometry, total gas flow, powder feed rate, stand-off distance, and particle size distribution. Details of these investigations can be found elsewhere [18] and HVOF microstructure will be further discussed in the following. Consequently, these coatings own higher crystallinity regardless of the lower deposition temperature in the process as un-melted part of the particles remain crystalline. An added benefit of low flame temperature is diminished Si-evaporation from the particles during spraying. It can be seen from Figure 12a that the detected Yb$_2$SiO$_5$ content from about 50 wt.% crystalline HVOF coating is about 5 wt.% which fits well to the feedstock composition although of course the large amorphous content has to be considered.

![Temperature vs. Time](image)

Figure 13. Recorded temperature measurements using a thermocouple during VLPPS deposition of Yb$_2$Si$_2$O$_7$ on monolithic SiC substrate.

The microstructure of the coatings sprayed from Yb$_2$Si$_2$O$_7$ feedstock with APS, HVOF and VLPPS processes can be seen in Figure 14. The two APS coatings (a,b) that were deposited at different temperatures (Figure 14a is the “standard” APS sample and b is deposited at a higher temperature, further details are discussed below) have vertical cracks running through the thickness of the coatings which is associated with the higher thermal stresses in these coatings due to the significant amount of Yb$_2$SiO$_5$ content (about 30 wt.% in these coatings determined after crystallization heat treatment). Because thermal expansion coefficient of Yb$_2$SiO$_5$ (7.5 $\times$ 10$^{-6}$ °C$^{-1}$) is larger than that of the Yb$_2$Si$_2$O$_7$ (4.7 $\times$ 10$^{-6}$ °C$^{-1}$) as well as the SiC/SiC substrate (5.1 $\times$ 10$^{-6}$ °C$^{-1}$) [37]. This leads to greater tensile thermal stresses in the oxide coating after cooling, along with the tensile quenching stresses, which induce the vertical cracking. The high amorphous content in the APS layer would even further increase the CTE mismatch, however simultaneously due to a reduced Young’s modulus of the amorphous state, the effect on the stress level might be limited. Therefore, as cracks are not desired in the EBC microstructure, it is of crucial importance to minimize Si-evaporation during spraying.
was associated with the higher crystallinity in the coating (b). Seemingly, heterogeneous nucleation was analysed in the preceding section and shown in Figure 14a, the APS coating shown in Figure 14b as density increases in the crystallizing zone, the volume is reduced which induces elastic tensile stresses within the amorphous region. Pores within the splat, therefore, nucleate when these stresses propagate. The un-melted particles can be avoided for instance by decreasing the particle size of the feedstock but that means higher amorphous content and Yb$_2$SiO$_5$ phase in the layer at the same time. Figure 14d shows the microstructure of a VLPPS layer that is free of vertical cracks, dense and also crystalline in the as-sprayed state, which makes it a very promising method developed for EBC manufacturing in Jülich. High deposition temperatures (min. 1000 °C) and moderate cooling rates (approx. 55 K/min) in the process as shown in Figure 13 evidently helps for crystallization as well as for stress relaxation in the layer. Further investigations are ongoing in this direction to understand the effect of deposition temperature and cooling rates on crystallization kinetics and related mechanical properties in the layer, as well as the stress state in the EBC system.

Figure 14. Microstructure of the coatings sprayed from Yb$_2$Si$_2$O$_7$ feedstock using (a,b) APS, (c) HVOF and (d) VLPPS process. Note that both APS coatings (a,b) were sprayed with 520 A current and 90 mm spray distance but deposition temperatures were about 550 °C and 900 °C at a and b, respectively (see text).

Both APS coatings (Figure 14a,b) were sprayed at similar conditions but sample size in (b) was very small ($3 \times 3.8 \times 36$ mm$^3$) and as a result of that a maximum deposition temperature of about 900 °C could be reached for this particular sample. Therefore, in contrast to standard size APS sample that was analysed in the preceding section and shown in Figure 14a, the APS coating shown in Figure 14b is highly crystalline (76 wt.%). The porosity content of the two APS coatings are also dissimilar, i.e., the coating (a) is significantly denser than the coating (b). This difference between the microstructures was associated with the higher crystallinity in the coating (b). Seemingly, heterogeneous nucleation takes place at the splat boundaries during cooling while the centre of the splats remains amorphous. As density increases in the crystallizing zone, the volume is reduced which induces elastic tensile stresses within the amorphous region. Pores within the splat, therefore, nucleate when these stresses are large enough. Other relevant theories to the formation of pores are discussed elsewhere [20].

No vertical cracking was observed in the fairly dense HVOF layer (Figure 14c), presumably due to lower Yb$_2$SiO$_5$ content and hence reduced thermal stresses in the process as a result of the lower particle and deposition temperatures, respectively. However, isothermal thermal cycling experiments revealed that the adhesion of the HVOF oxide layer on the Si bond coat is poor because the HVOF layer partially delaminated only after few cycles [18]. The short lifetime of the layer was attributed to the presence of un-melted particles at the interface wherein the cracks can easily propagate. The un-melted particles can be avoided for instance by decreasing the particle size of the feedstock but that means higher amorphous content and Yb$_2$SiO$_5$ phase in the layer at the same time. Figure 14d shows the microstructure of a VLPPS layer that is free of vertical cracks, dense and also crystalline in the as-sprayed state, which makes it a very promising method developed for EBC manufacturing in Jülich. High deposition temperatures (min. 1000 °C) and moderate cooling rates (approx. 55 K/min) in the process as shown in Figure 13 evidently helps for crystallization as well as for stress relaxation in the layer. Further investigations are ongoing in this direction to understand the effect of deposition temperature and cooling rates on crystallization kinetics and related mechanical properties in the layer, as well as the stress state in the EBC system.
While a variety of coating morphologies can be obtained with thermal spray processes, characteristics of the coatings, typically the size of microstructural features, is controlled by the used feedstock [38]. For example, the size of intersplat pores is directly depending on the size and shape of powdery feedstocks. Since a well flowable powder in the size range of about 10–100 µm is usually applied for conventional plasma spraying, there is a minimum size for application of powdery feedstock. Suspension plasma spray would be one of alternative processes for conventional ones in this context. Suspension plasma spraying is one of the rather new thermal spray techniques, which has a liquid feedstock and relatively higher plasma power compared with conventional ones. Especially, SPS could supply a great diversity in microstructural features from columnar and porous to bulk-like dense ones [39,40]. Main processing parameters, such as gun power, spraying distance, roughness, and particle size distribution in suspension, would play an important role in controlling the microstructures fabricated by SPS.

Figure 15 shows the cross-sectional microstructures of Yb$_2$Si$_2$O$_7$ coatings fabricated by using the SPS technique with different spraying distances of 50 and 70 mm. As seen especially in the higher magnification images, bulk-like dense microstructure can be obtained within this work regarding gun power, spraying distance and particle size distribution in suspension feedstock. Vertical cracks in the coating microstructure were inevitable because of tensile stress from rapid cooling after spraying as can be seen in Figure 15c.

![Figure 15. Microstructure of the coatings sprayed from Yb$_2$Si$_2$O$_7$ suspension by using SPS with a gun distance of (a,b) 50 mm and (c,d) 70 mm.](image)

Figure 16 reveals how the stand-off distance influences the substrate temperature and by that e.g., the degree of crystallization. Shorter stand-off distances give higher temperatures and by that also better splat bonding and reduced relaxation, which give a higher segmentation crack density. Figure 17 shows the X-ray diffraction patterns of Yb$_2$Si$_2$O$_7$ coatings fabricated by using the SPS technique with different spraying distance. Considerable amounts of the amorphous phase were observed from EBC with long spraying distance (90 mm). In the case of short spraying distance (50 mm), the degree of
crystallinity was around 80%, which was calculated from the areal intensity ratio between crystalline peaks and amorphous humps of XRD.

![Substrate temperature and crack density as function of the spraying distance.](image)

**Figure 16.** Substrate temperature and crack density as function of the spraying distance.

![X-ray diffraction patterns from YDS EBCs fabricated by using suspension plasma spraying with spraying distance of 50, 70, or 90 mm. Arrows indicate amorphous baselines in XRD.](image)

**Figure 17.** X-ray diffraction patterns from YDS EBCs fabricated by using suspension plasma spraying with spraying distance of 50, 70, or 90 mm. Arrows indicate amorphous baselines in XRD.

4. Conclusions

This study summarizes insights into the development of EBCs for both oxide- and non-oxide-based CMCs. Results of coating experiments with different ceramic powders on an Al₂O₃/Al₂O₃ CMC were presented; the samples were furnace cycled to test the high temperature behaviour. Coatings of Y₂O₃ and Gd₂Zr₂O₇ showed promising results, as they were crystalline and dense in the as-sprayed state. Y₂O₃ coatings showed excellent adhesion due to the formation of chemical bonds between coating and substrate. In contrast to this, Gd₂Zr₂O₇ coatings tend to fail during cycling because of bad
contact between coating and substrate. The coating adhesion could be significantly increased by laser structuring of the CMC before coating.

$Y_2SiO_5$ coatings could be prepared with rather high crystallinity (nearly 70%). Heat treatment led to the formation of a fine-grained microstructure with the major phase $Y_2SiO_5$ and a considerable amount of $Y_2O_3$ without delamination after cooling.

$Yb_2Si_2O_7$ coatings have been produced by different thermal spray process, namely, APS, HVOF, VLPPS, and SPS. APS can deliver dense coatings with a high degree of amorphous phase content. HVOF gives rather crystalline coatings with acceptable porosity levels, VLPPS gives even better coatings. Furthermore, SPS can give a high degree of crystallinity, however segmentation cracks are difficult to avoid.

A summary of the outcome reflecting the actual situation as seen in our institute is given in Table 4. So, our message is that also other thermal spray methods than APS can be used to obtain promising EBCs. Certainly, further improvements of processes can change the ranking in this evaluation.

Table 4. Comparison of the used thermal spray processes for the deposition of EBCs (o reflects average, - (– very) bad, + (++ very) good results with respect to the criteria).

<table>
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Author Contributions: R.V.: writing—original draft preparation, supervision, review and editing; E.B.: investigation, writing—original draft preparation; C.G.: investigation, writing—original draft preparation; S.K.: investigation, writing—original draft preparation; D.E.M.: supervision, review and editing; O.G.: supervision, review and editing.

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